Supporting Information for

Super high-performance 7-atomic-layer thermoelectric materials ZrGe₂N₄

Wei Liu, Yuee Xie*, Jiaren Yuan and Yuanping Chen^\dagger

School of Physics and Electronic Engineering, Jiangsu University, Zhenjiang, 212013, Jiangsu, China

^{*†} Corresponding author: <u>Yueex@ujs.edu.cn</u>; <u>Chenyp@ujs.edu.cn</u>.



Figure S1. Phonon spectra and phonon projection density of states (PPDOS) of (a) 3-atomic-layer MoS₂, (b) 3-atomic-layer WS₂, (c) 3-atomic-layer ZrS₂, (d) 3-atomic-layer MoSe₂, (e) 3-atomic-layer WSe₂, (f) 3-atomic-layer ZrSe₂, (g) 7-atomic-layer MoSi₂N₄, (h) 7-atomic-layer WGe₂N₄, (i) 7-atomic-layer ZrSi₂N₄, (j) 7-atomic-layer MoSi₂P₄, (k) 7-atomic-layer WGe₂As₄ and (l) 7-atomic-layer ZrSi₂P₄.



Figure S2. Phonon spectra of (a) 7-atomic-layer ZrGe₂P₄, (b) 7-atomic-layer ZrGe₂As₄, (c) 7-atomic-layer ZrSn₂P₄, (d) 7-atomic-layer ZrSn₂As₄.



Figure S3. 2D view of the electron localization function (ELF) of ZrGe₂N₄, 1 and 0 correspond to the areas with perfectly localized and vanished electron density, respectively



Figure S4. (a) Specific heat capacity (C_V) of 7-atomic-layer ZrGe₂N₄. (b) Phonon group velocity (ν) of 7-atomic-layer ZrGe₂N₄



Figure S5. Time-dependent energy of 7-atomic-layer $ZrGe_2N_4$ at 2000 K. Inset: Relaxation structure at 2000 K.